



THE UNITED STATES PATENT AND TRADEMARK OFFICE

#3 / 105
12-13-00
R. Stiles

In re application of: Vishnu K. Agarwal

Serial No.: 09/652,841

Filed: 8/31/00

For: DEVICE AND METHOD FOR PROTECTING
AGAINST OXIDATION OF A CONDUCTIVE LAYER IN SAID
DEVICE

§ Group Art Unit: 2815
§ Examiner:
§ Atty. Docket: 98-0616.02
§ Paper No.
§

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INFORMATION DISCLOSURE STATEMENTAssistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56, Applicant respectfully requests that this Information Disclosure Statement be entered and that the references listed on the attached Form PTO-1449 be considered by the Examiner and made of record. Copies of the listed references are enclosed for the convenience of the Examiner.

In accordance with 37 C.F.R. § 1.97(b), this Information Disclosure Statement is not to be construed as a representation that a search has been made or that no other possible material information as defined in 37 C.F.R. § 1.56(a) exists.

The following references are submitted for the Examiner's review:

U.S. PatentsU.S. Patent No. Issue Date Inventor

5,853,500	12/29/98	Joshi et al.
5,852,307	12/22/98	Aoyama et al.
5,670,808	09/23/97	Nishihori et al.
5,440,174	08/08/95	Nishitsuji

As this information is being submitted within three months of the date of filing of the application, Applicant understands that no fee or certification is required for the submission and consideration of this information at this time.

If there are any matters which may be resolved or clarified through telephone interview, the Examiner is respectfully requested to contact Applicant's undersigned attorney at the number indicated.

* * * *

A Form PTO-1449 is enclosed herewith.

Date: 11/14/00



Respectfully submitted,

A handwritten signature in black ink that reads "Charles Brantley".

Charles Brantley
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